



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#11/Amend B
Amend
8/10/01

Applicant(s):

Hsiao, Tommy C.; Hui, Angela T.; Ogle, Robert B.; Pham, Tuan Duc;
Plat, Marina V.; Ramsbey, Mark T.; Shen, Lewis

Assignee: Advanced Micro Devices, Inc.

Title: Polished Flash Process With Metal Gates And Improved Planarity

Serial No.: 09/430,366 Filing Date: October 28, 1999

Examiner: J. Chen Group Art Unit: 2813

Docket No.: M-7523 US

Newport Beach, California
August 6, 2001

BOX RCE
COMMISSIONER FOR PATENTS
Washington, D. C. 20231

RESPONSE TO OFFICE ACTION

Dear Sir:

This is a response to the April 6, 2001 Office Action. Submitted herewith are also the following documents:

1. A petition for a one-month extension of time pursuant to 37 CFR 1.136(a).
2. A Request for Continued Examination (RCE) pursuant to 37 CFR 1.114.
3. A written statement summarizing a telephonic interview with Examiner Jack

Chen held on August 3, 2001, pursuant to 37 CFR 1.133(b).

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